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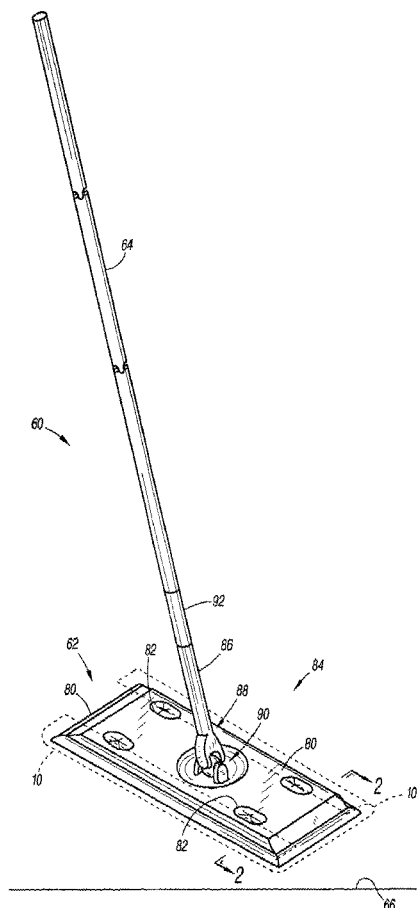
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- (71) Applicant: **S.C. JOHNSON & SON, INC.** [US/US]; 1525 Howe Street, Racine, WI 53403 (US). Published: — without international search report and to be republished upon receipt of that report
- (72) Inventors: **BROWN, Colin, W.**; 5 Clandon Avenue, Egham, Surrey TW20 8LP (GB). **FRANCIS, Edward**; 3520 South Lane, Franksville, WI 53126 (US). For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

(54) Title: PARTICLE ENTRAPMENT SYSTEM



(57) Abstract: A cleaning sheet for cleaning and removing particles from a surface is disclosed. The sheet includes a particle retention layer including an electret material for collecting and retaining the particles. The sheet also includes an outer layer covering at least a portion of the particle retention layer. The outer layer comprises a low dust retention material and includes a surface having a plurality of apertures formed therethrough.

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